

EAST Search History

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|-------|---|----------------------------|------------------|---------|------------------|
| L1 | 63617 | (chemical\$4 NEAR5 mechanical\$4 NEAR5 (polish\$4 OR planari\$4)) OR CMP\$4 | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:15 |
| L2 | 37603 | L1 AND (silica\$4 OR (silicon\$4 ADJ oxide\$4) OR SiO2 OR "SiO.sub.2") | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:15 |
| L3 | 3118 | L2 AND (organic\$4 NEAR3 acid\$4) | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:15 |
| L4 | 1713 | L3 AND ((oxidiz\$4 NEAR3 agent\$4) OR oxidiz\$4) | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:13 |
| L5 | 422 | L4 AND ((copper\$4 OR Cu) NEAR20 barrier\$4) | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:14 |
| L6 | 261 | L5 AND corrosion\$4 | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:14 |
| L7 | 6057 | ((438/690-693) or (252/79.1) or (510/175,176) or (216/88-91)). CCLS. | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:14 |
| L8 | 121 | L6 AND L7 | US-PGPUB; USPAT | OR | OFF | 2006/04/20 09:15 |
| L9 | 19062 | (chemical\$4 NEAR5 mechanical\$4 NEAR5 (polish\$4 OR planari\$4)) OR CMP\$4 | EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/04/20 09:15 |
| L10 | 1667 | L9 AND (silica\$4 OR (silicon\$4 ADJ oxide\$4) OR SiO2 OR "SiO.sub.2") | EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/04/20 09:15 |
| L11 | 64 | L10 AND (organic\$4 NEAR3 acid\$4) | EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/04/20 09:15 |